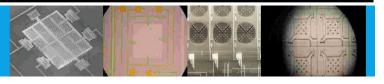
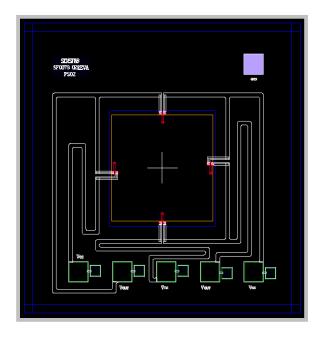


**Uncompensated Pressure Sensor Die** 





The MTPD007 series piezo-resistive pressure sensor dies are manufactured on six inch silicon wafers in a class 100 clean room using a state of the art 1.2 micron CMOS facility and are then bulked micro-machined in a class 1000 clean room. The wafers are batch manufactured using a electrochemical etch stop process to achieve excellent repeatability.

Applied pressure deforms a diaphragm causing piezo-resistors to change their resistance. This change in four resistors, which constitute a Wheat Stone Bridge, results in a pressure-proportional voltage.

Die are probed, inked, diced and visually inspected and shipped on tapes, in rings or in waffle packs. Dies can be mounted on ceramic or PCB substrates or packaged in application specific packages for measuring pressure in non-corrosive media.

### **FEATURES**

- Piezo-resistive bridge
- Surface passivation
- Solid state
- High reliability
- Optimally sized for application
- Low cost design
- Suitable for invasive applications
- Meets industry specifications
- 6" wafer availability
- 100% factory tested
- Excellent repeatability
- Rated pressure of sensor 0 to 7 psi

### THE MAIN FIELD OF APPLICATIONS

- ✓ Medical instrumentation
- ✓ Blood pressure measurement
- ✓ Infusion pumps
- ✓ Kidney dialysis machines



### **Uncompensated Pressure Sensor Die**

### **TECHNICAL DATA**

### **Maximum ratings**

Specification	Min.	Тур.	Max.	Unit
Operating Temperature	-40	-	85	℃
Storage Temperature	-40	-	125	℃
Supply Voltage	+1	6	10	V
Operating Current	-	2.5	-	mA

#### Data

Temperature=22±2°C, Relative humidity=45±5%, Supply voltage=6V

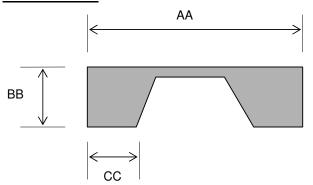
Specification	Min.	Тур.	Max.	Unit
	-30	-	+300	mmHg
Operating Pressure Range	-0.6	-	5.8	psi
	-4	-	40	kpa
	-0.04	-	0.4	bar
	125	-	-	psi
Over Pressure	6463	-	-	mmHg
	862	-	-	kpa
	8.6	-	-	bar
Zero Pressure Offset Voltage	-3	-1.5	0	mV/V
	32	39	45	μV/V/mmHg
Soncitivity	1.7	2.0	2.3	mV/V/psi
Sensitivity	0.2	0.3	0.3	mV/V/kpa
	145	177	204	mV/bar
Span	69	85	98	mV
Non Linearity	-	+0.5	+1	%FSO
Bridge Resistance (see note 5)	1000	1150	1300	Ω
TCO	-	-	±0.3	mmHg/℃
TCR	1100	1500	1800	ppm/℃
TCS	-	-	-0.1	%/℃

- 1. Supply voltage DC and AC up to 5kHz,  $V_{pp}$  = 10V  $\pm$  0.1 VDC
- 2. Current is linear in full range
- 3. Total error at half span is based on the difference between half span measurement and a straight line projection over the span of the device where  $o(\frac{s}{2})^{-\frac{O(0)+O(S)}{2}}$
- 4. Top side pressure application
- 5. Resistance is measured by sourcing a constant current of 2.5mA
- 6. Parameters (except zero pressure offset which is measured directly) are computed from individual piezo-resistance measurements made at different pressures under application of a current of 2.5mA, which represents the typical operating conditions
- 7. TCO, TCR & TCS are tested from 0°C to 50°C



**Uncompensated Pressure Sensor Die** 

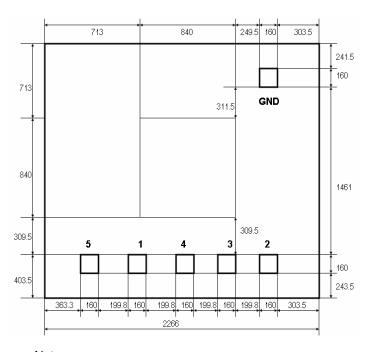
## **DIMENSIONS**



Dim.	Typical	Tolerance	Units
AA	2266	± 0.33	μm
BB	541	± 10	μm
CC	345.5	± 2.33	μm
Dicing Process	60	± 15	μm

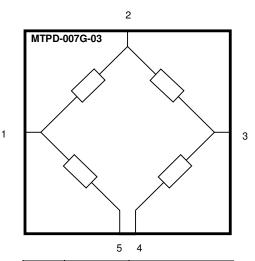
Note: Dimension AA & CC are prior to dicing process.

### **ELECTRICAL AND DIE LAYOUT**



### Note

- All dimensions are in μm.
- Mask fabrication tolerance of ±0.3um
- Design fabrication tolerance of ±0.03um



Pad	Symbol	Description	
1	V <sub>out</sub> +	Output voltage	
2	V <sub>cc</sub> +	Supply voltage	
3	V <sub>out</sub> -	Output voltage	
4	V <sub>cc</sub> -	Supply voltage	
5	V <sub>cc</sub> -	Supply voltage	
GND	GND	Ground	

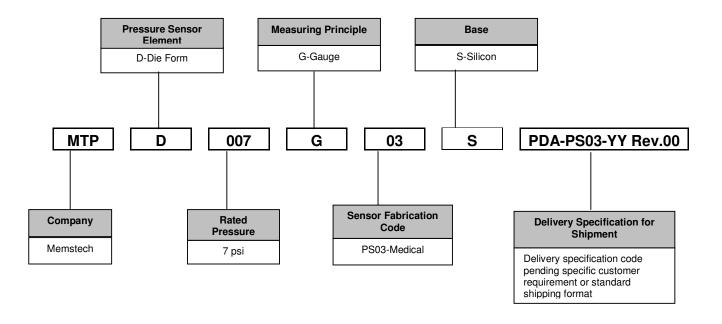
MEMSENZ™ I Transduction Principle Capacitive Processing Technology Bulk/Deep RIE Actuation Mechanism Force (External) Signal Condition Two chips/Single chip MEMSENZ™ II Transduction Principle Piezoresistive Processing Technology Bulk/Deep Wet Etch Actuation Mechanism Pressure (External) Signal Condition Two chips/Single chip MEMSENZ™ III
Transduction Principle
Resistive
Processing Technology
Surface
Actuation Mechanism
Thermal
Signal Condition
Two chips

MEMSENZ™ IV
Transduction Principle
Capacitive
Processing Technology
Bulk
Actuation Mechanism
Sound
Signal Condition
Two chips



**Uncompensated Pressure Sensor Die** 

## **HOW TO SPECIFY PART NUMBER**



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Processing Technology
Surface
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Thermal
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Sound
Signal Condition
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